	Application No.	Applicant(s)
Notice of Allowability	10/596,573	HE ET AL.
	Examiner	Art Unit
	VONGSAVANH SENGDARA	2826
The MAILING DATE of this communication apperature All claims being allowable, PROSECUTION ON THE MERITS IS herewith (or previously mailed), a Notice of Allowance (PTOL-85) NOTICE OF ALLOWABILITY IS NOT A GRANT OF PATENT RIOF of the Office or upon petition by the applicant. See 37 CFR 1.313	(OR REMAINS) CLOSED in this a or other appropriate communication IGHTS. This application is subject	pplication. If not included on will be mailed in due course. <b>THIS</b>
1. $\boxtimes$ This communication is responsive to <u>amendment filed on 0</u>	<u>08/27/2009</u> .	
2. The allowed claim(s) is/are <u>12-19</u> .		
<ul> <li>3. Acknowledgment is made of a claim for foreign priority ur</li> <li>a) All b) Some* c) None of the:</li> <li>1. Certified copies of the priority documents have</li> <li>2. Certified copies of the priority documents have</li> <li>3. Copies of the certified copies of the priority documents have</li> <li>International Bureau (PCT Rule 17.2(a)).</li> </ul>	e been received. e been received in Application No.	
* Certified copies not received:		
Applicant has THREE MONTHS FROM THE "MAILING DATE" of this communication to file a reply complying with the requirements noted below. Failure to timely comply will result in ABANDONMENT of this application.  THIS THREE-MONTH PERIOD IS NOT EXTENDABLE.		
4. A SUBSTITUTE OATH OR DECLARATION must be submitted. Note the attached EXAMINER'S AMENDMENT or NOTICE OF INFORMAL PATENT APPLICATION (PTO-152) which gives reason(s) why the oath or declaration is deficient.		
5. CORRECTED DRAWINGS ( as "replacement sheets") must be submitted.		
(a) ☐ including changes required by the Notice of Draftsperson's Patent Drawing Review ( PTO-948) attached		
1) 🔲 hereto or 2) 🔲 to Paper No./Mail Date		
(b) ☐ including changes required by the attached Examiner's Amendment / Comment or in the Office action of Paper No./Mail Date		
Identifying indicia such as the application number (see 37 CFR 1.84(c)) should be written on the drawings in the front (not the back) of each sheet. Replacement sheet(s) should be labeled as such in the header according to 37 CFR 1.121(d).		
6. DEPOSIT OF and/or INFORMATION about the deposit of BIOLOGICAL MATERIAL must be submitted. Note the attached Examiner's comment regarding REQUIREMENT FOR THE DEPOSIT OF BIOLOGICAL MATERIAL.		
Attachment(s)	5 DNaCas attacks	Detect Application
<ol> <li>Notice of References Cited (PTO-892)</li> <li>Dotice of Draftperson's Patent Drawing Review (PTO-948)</li> </ol>	5.	
<ol> <li>Information Disclosure Statements (PTO/SB/08),</li> </ol>		ate <u>attached hereto</u> .
Paper No./Mail Date  4.  Examiner's Comment Regarding Requirement for Deposit		nent of Reasons for Allowance
of Biological Material	9. ☐ Other	ioni or reducing for Allowallice
/Minh-Loan T. Tran/		
Primary Examiner Art Unit 2826		



Application No.

## **DETAILED ACTION**

## Examiner's Amendment

An examiner's amendment to the record appears below. Should the changes and/or additions be unacceptable to applicant, an amendment may be filed as provided by 37 CFR 1.312. To ensure consideration of such an amendment, it MUST be submitted no later than the payment of the issue fee.

Authorization for this examiner's amendment was given in a telephone interview with Todd M.C. Li on 11/18/2009. An examiner's amendment to the record appears below.

In claim 12,

line 3 is changed from "providing said substrate" - to - "providing a substrate"; and

line 4 is changed from "forming said first type device and said second type device positioned on said" – to – "forming a first type device and a second type device positioned on said"; and

line 5 is changed from "substrate, such that said uppermost surface of said first type device is higher than said" - to - "substrate, such that an uppermost surface of said first type device is higher than an"; and line 11 is changed from "surface of said first type device so that the top surface of said passivating layer has a" - to - "surface of said first type device so that a top surface of said passivating layer has a"; and

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line 22 is changed from "forming said first device contact embedded within said insulating layer of said' - to - "forming a first device contact embedded within said insulating layer of said".

## Reasons for Allowance

Claims 12-19 are allowed.

The following is an examiner's statement of reasons for allowance:

The prior art of record, either singly or in combination, does not discloses or suggests the combination of limitations recited in the base claims 12 and 13, including the combination of an integrated circuit structure and the method of forming the integrated structure comprising: a substrate; a first type device and a second type device positioned on said substrate, said first type device having an uppermost surface that is higher than an uppermost surface of said second type device; a passivating layer positioned above said substrate and between said first and second type devices, wherein said passivating layer has a top surface substantially coplanar with said uppermost surface of said first type device.

Any comments considered necessary by applicant must be submitted no later than the payment of the issue fee and, to avoid processing delays, should preferably accompany the issue fee. Such submissions should be clearly labeled "Comments on Statement of Reasons for Allowance."

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## Conclusion

Any inquiry concerning this communication or earlier communications from the examiner should be directed to VONGSAVANH SENGDARA whose telephone number is (571)270-5770. The examiner can normally be reached on flex schedule.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Sue Purvis can be reached on (571)272-1236. The fax phone number for the organization where this application or proceeding is assigned is 571-273-8300.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free). If you would like assistance from a USPTO Customer Service Representative or access to the automated information system, call 800-786-9199 (IN USA OR CANADA) or 571-272-1000.

/V. S./ Examiner, Art Unit 2826 /Minh-Loan T. Tran/ Primary Examiner Art Unit 2826